



## Capital Markets Day 2022

# Technology and Manufacturing

## **Orio Bellezza**

President, Technology, Manufacturing, Quality and Supply Chain

## ST's technology and manufacturing strategy is a key business enabler

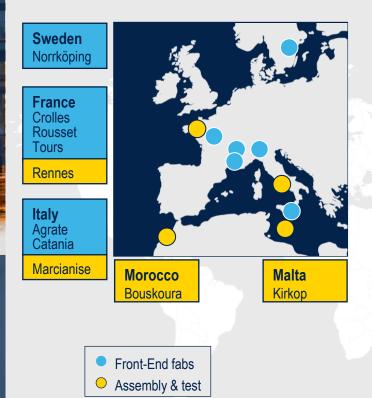
## In-house manufacturing complemented by outsourcing

- Fast and competitive growth
- Reliable supply chain for our customers
- Product differentiation through proprietary technologies
- Access to leading-edge digital technologies in foundry

## Mid-term strategy

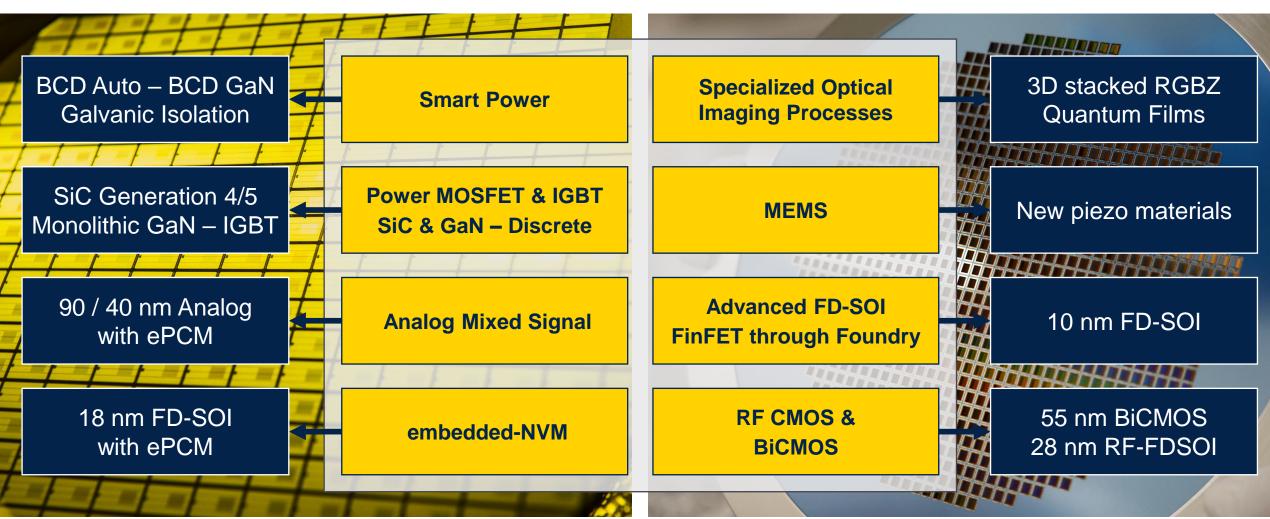
- 300 mm double internal capacity
- Silicon Carbide growth, vertical integration and 200 mm
- Gallium Nitride internal 200 mm manufacturing
- Expand collaborations with key foundries and OSATs \*

### ST in-house manufacturing





# Our proprietary front-end technologies enable product differentiation





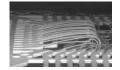
## Focused innovation in assembly and testing & OSAT collaboration support our strategy

Innovation focus for packaging supporting strategy
Internal manufacturing and collaboration with subcontractors

### **Smart Mobility**



SiC Power modules for car electrification

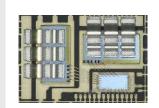


Low cost / Hi-Rel BGA/QFP for MCU

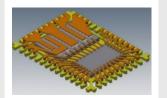


Advanced FCBGA for ADAS

### **Power & Energy**



Power SiP for smart power solutions - GaN, BCD, ViPower



Direct Copper interconnect for low impedance

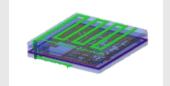
## IoT & Connectivity



WLCSP pervasion for smartphone & wearable



Sensor package ultra miniaturization (ToF, MEMS)



Antenna integration for mmWave



BGA: Ball Grid Array
QFP: Quad Flat Package
FCBGA: Flip Chip Ball Grid Array
WLCSP: Wafer Level Chip Scale Package

## Strategic manufacturing programs update

## 300 mm expansion



- Second phase of modular expansion completed and third module under construction
- Possible further modular expansion



- Equipment installation ongoing
- Wafer start Q3 2022, volume ramp in H1 2023

300 mm footprint by 2025

## Wide bandgap

### Silicon Carbide vertical integration

Expanding production in Catania and Singapore **front-end** fabs and starting 200 mm production

Growing in Shenzhen and Bouskoura assembly & test plants

ST-SiC **substrate pilot line** delivering limited volumes of 150 mm and 200 mm wafers

**New plant** for internal production by 2023

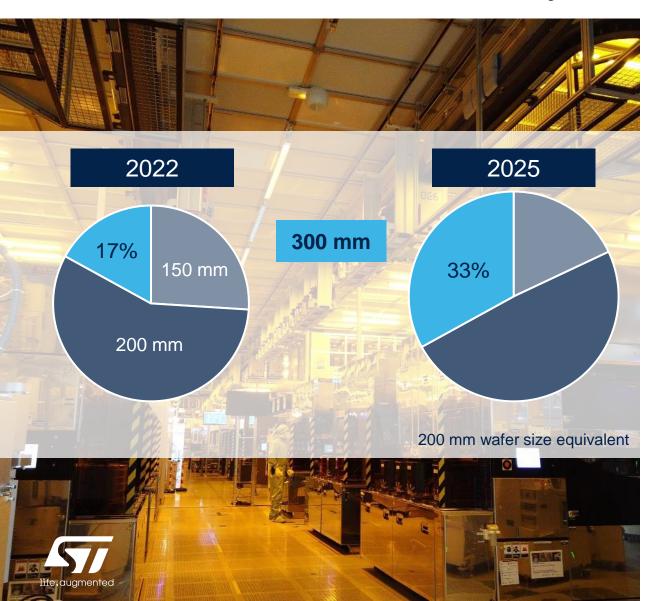
#### **Gallium Nitride**

- Internal 200 mm line and Epi center completed in Tours. Volume production in 2023
- Power GaN production in TSMC



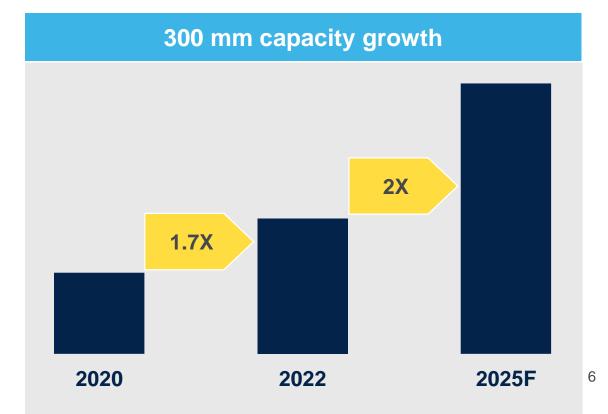


## 300 mm manufacturing capacity expansion is key to our \$20B+ revenue ambition









## Agrate 300 – Progressing for ramp-up in 2023

## **Status and planning**

- Equipment installation ongoing wafer start in Q3 22
- Production qualification by H1 2023
- Fast ramp capacity sharing with Tower Semiconductor





## Agrate – Crolles synergy

- Process transfer from Crolles for faster qualification
- Road-map alignment : Analog mixed signal, BCD, eNVM
- Designed-in interoperability between the two fabs
   digital twins



## Accelerating expansion of silicon carbide device manufacturing capacity

### In volume production with SiC devices since 2017

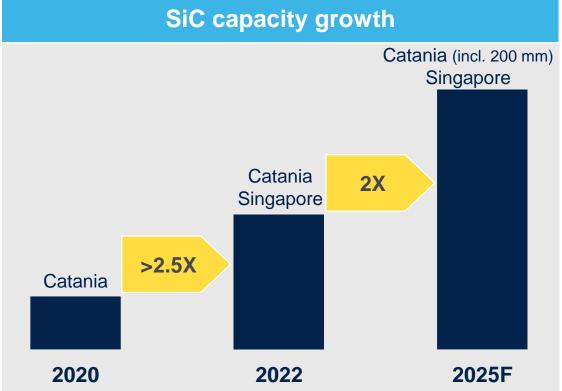
- More than 125 million devices shipped to automotive customers
- Capacity expanded more than 2.5X by 2022 vs 2020

### Further >2X and 200 mm by 2025

- 200 mm volume production by 2023
- Assembly & test at two sites: Shenzhen & Bouskoura









# Silicon Carbide vertical integration targeting > 40% substrate in-sourcing by 2024

## **ST-SiC** substrate plant



150 mm volume production

200 mm with industrial quality and yields









## Building Gallium Nitride capabilities and capacity to support business ambitions

### Power Conversion GaN and RF-Power GaN

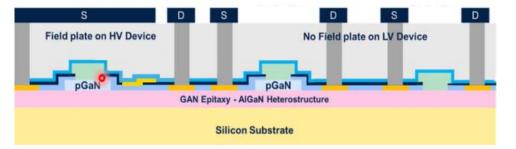
### 200 mm Power GaN fab in Tours

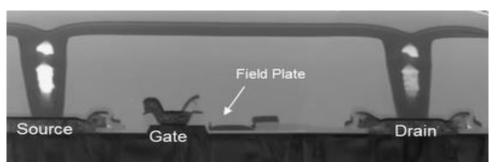
- Epi capability and pilot line in place
- Fab qualification in 2022
- Volume production ramp in 2023

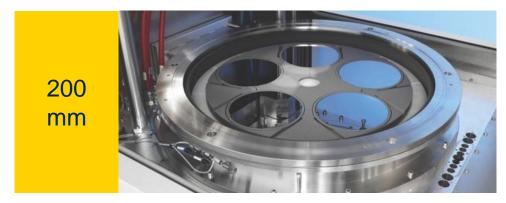
#### 150 mm RF-GaN in Catania

Fab qualification in 2022

**Integrated-GaN and BCD-GaN in development** 

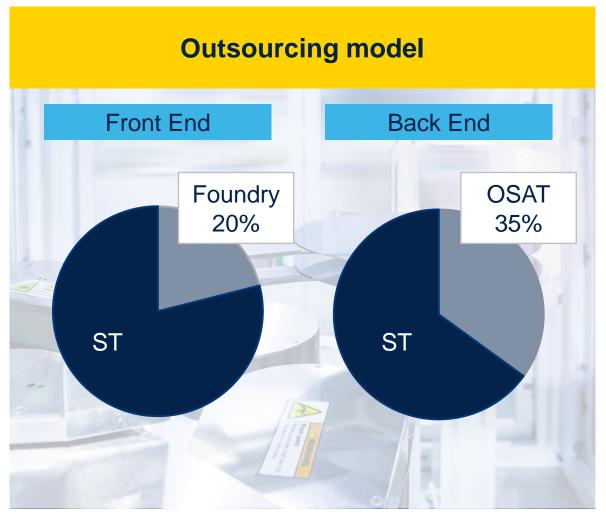








## Strategic manufacturing outsourcing



### **Collaboration model**

Collaboration with **leading foundries and OSATs** enable access to selected advanced technologies, complementing our portfolio

#### Front-end

**TSMC**: Leading edge FinFET

Samsung Foundries & Globalfoundries: FD-SOI

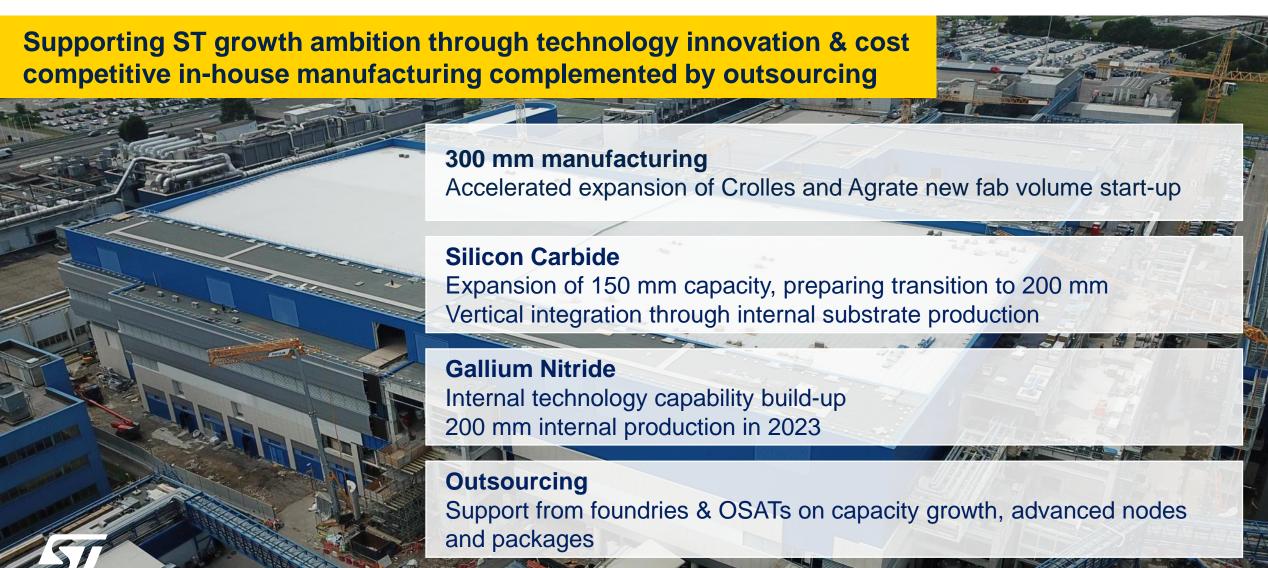
ecosystem

Back-end (Assembly & Test)

**ASE, AMKOR**: Advanced BGA & WLCSP packages



# Creating value from our IDM model supporting ST \$20B+ revenue ambition



## Our technology starts with You



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